PHYSICS SPECIFICATIONS FOR THE LINAC OTR PROFILE MONITORS

Henrik Loos  
Author  
Signature  
Date  
06/17/07

Eric Bong  
System Manager  
Signature  
Date  
Jun 17/07

Paul Emma  
Accelerator Physics Team Leader  
Signature  
Date  
1/18/07

Cecile Limborg  
Injector Physicist  
Signature  
Date  
Jun 08 - 07

Darren Marsh  
Quality Assurance Manager  
Signature  
Date  
1/18/07

John Galayda  
Project Director  
Signature  
Date  
11/22/07

Brief Summary:  
This document describes the location and performance requirements for the linac beam profile monitors using optical transition radiation (OTR) from a metal screen.

Change History Log:

<table>
<thead>
<tr>
<th>Rev Number</th>
<th>Revision Date</th>
<th>Sections Affected</th>
<th>Description of Change</th>
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<tbody>
<tr>
<td>000</td>
<td>Feb. 16, 2006</td>
<td>All</td>
<td>Initial Version</td>
</tr>
<tr>
<td>001</td>
<td>Dec. 14, 2006</td>
<td>All</td>
<td>Added OTR22, updated Table 1</td>
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Physics Specifications for the Linac OTR Profile Monitors

This document gives the specifications for the 8 OTR profile monitors (view screens) in the linac and is based on the detailed information found in the PRD 1.2-21 [Physics Specifications for the Injector Profile Monitors (YAG & OTR)]. Here only the differences with respect to the injector profile monitors will be documented. The specifications are given in Table 1. All screens are Aluminum.

Table 1.
Numbers for the beam size in brackets refer to special modes of operation and specify the full extent of the beam whereas the numbers without brackets refer to the nominal rms beam size at 1-nC bunch charge. The minimum beam size $\sigma_{\text{min}}$ is for a 0.2-nC charge and refers to the smallest of x or y. $S_{\text{Position}}$ is the screen distance from the cathode, and “Direction” specifies either the axis in which the OTR light is reflected or a close-to-normal incidence reflection. “Diameter” is the clear diameter of the foil.

<table>
<thead>
<tr>
<th>OTR</th>
<th>Resolution [µm]</th>
<th>Diameter [mm]</th>
<th>Thickness [µm]</th>
<th>Nominal Energy [GeV]</th>
<th>Direction</th>
<th>$\sigma_{\text{min}}$ [µm]</th>
<th>$\sigma_x$ [µm]</th>
<th>$\sigma_y$ [µm]</th>
<th>$S_{\text{Position}}$ [m]</th>
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<tbody>
<tr>
<td>OTR11</td>
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<td>1</td>
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<td>Vertical</td>
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<td>3800 [16000]</td>
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<td>20</td>
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<td>0.25</td>
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<td>40</td>
<td>41.52</td>
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<tr>
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<td>20</td>
<td>1</td>
<td>4.30</td>
<td>Vertical</td>
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<td>2600 [13000]</td>
<td>50</td>
<td>411.2</td>
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<td>Normal</td>
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<td>75</td>
<td>60 [600]</td>
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Optics and Camera

The standard optical setup and CCD camera used for many of the beam profile monitors in the injector (e.g. OTR3) will be used for all linac profile monitors (Fig. 1). The exception is OTR30 which requires a special design to achieve the focused field of view and resolution for this location. The beam splitter shall reflect about 90% of the light to maximize the amount of OTR light in the CCD and still enable to view the reticule. The strong synchrotron radiation background [1] at OTR11 and OTR21 shall be reduced by either a polarization sensitive beam splitter which transmits the horizontal and reflects the vertical polarization with a contrast of better than 20:1 or a polarization filter. Remote control is required for filter selection and illumination.
OTR_TCAV
The OTR_TCAV profile monitor will be used in a pulse stealing mode where the beam is horizontally kicked with the kicker BXKIK [2] upstream of the transverse cavity TCAV3 [3]. The OTR foil will be located off-axis (Fig. 2) with an adjustable horizontal position, including full retraction capability. The foil will be mounted at 45 degree to the beam to reflect the light horizontally. The edge of the foil mount will have a minimum 4-mm stay clear to the nominal beam axis. The foil mount shall be small enough to enable a pass through of the kicked beam 7 mm off axis. The diameter of the foil will be 20 mm to get a large enough vertical field of view for the calibration procedure of the transverse cavity.
Figure 2: Layout of the Vacuum chamber for the OTR_TCAV beam profile monitor.

**OTR30**
The resolution requirement for OTR30 can not be met over the full extent of the beam with a 45 degree foil angle. The foil shall therefore have an angle of less than 15 degree with respect to the beam axis and the OTR light shall be sent out of the vacuum chamber with an in-vacuum mirror leaving at least 8 mm stay clear for the electron beam. The in-vacuum path length shall not exceed 90 mm. A schematic of the setup is shown in Fig. 3. The imaging optics including the vacuum window shall provide the required resolution of 5 µm with a fixed 1:1 magnification within a 5-mm by 5-mm field of view. The distance of the lens to the foil needs remote adjustment. The CCD will be tilted at the same angle as the foil. (Alternatively, the in-vacuum mirror can be an off-axis paraboloid with an accompanying paraboloid to focus the light back into the CCD.)
Figure 3: Layout of the Vacuum chamber for the OTR30 beam profile monitor.

**Wakefield Mitigation**
No wakefield mitigation is required for the profile monitors in the linac.

**Radiation Shielding**
The radiation background during LCLS operation of the linac is expected to be low enough to cause no damage to the CCD and optical elements, even with the profile monitors inserted, due to the use of thin foils. However, sufficient shielding of the CCD and the optics for OTR11 through OTR_TCAV is required to prevent damage during non-LCLS operation. The CCD and the optics might be removed from the tunnel for special linac operations requiring very high charge, such as used during the E-158 experiments.

**References**